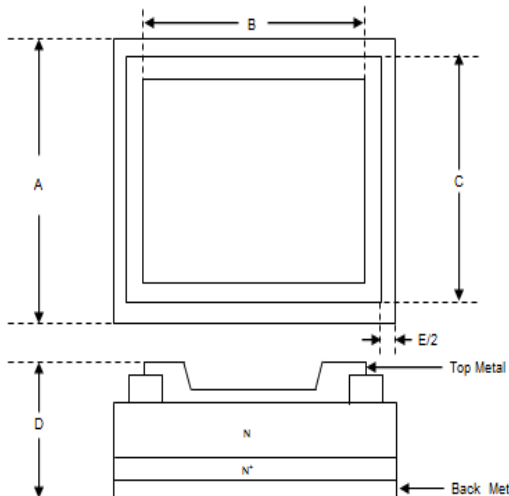


BM2150BG

150V, 20A⁽¹⁾, XTBR series Schottky

Mechanical Data

| Chip Drawing | Item | Information | |
|--|---|--|------------|
|  | Die Size (A) | 2590 μm | 102 mil |
| | Top Metal Pad Size (B) | 2405 μm | 94.7 mil |
| | Passivation Seal (C) | 2510 μm | 98.8 mil |
| | Wafer Thickness (D) | 254±15 μm | 10±0.6 mil |
| | Scribe Line Width (E) | 80μm | 3.15 mil |
| | Wafer Diameter | 6 inch | |
| | Gross Die | 2296 | |
| | Top Side Metallization/ Layer Thickness | Ag / 3 ±0.3 μm | |
| | Back Side Metallization/ Layer Thickness | Ag / 2 ±0.2 μm | |
| | Recommended Storage Environment | Store in original container, in dry nitrogen, (6 months at an ambient temperature of 23°C±3°C) | |

Electrical Characteristics in C/P test (T_J=25°C)

| Parameter | Description | Min. | Typ. | Max. | Unit | Test Condition |
|-----------------------------------|-----------------------------------|--------------------|------|------|------|-------------------------------------|
| V _{BR} | Reverse Breakdown Voltage | 150 | — | — | V | I _R = 300μA |
| V _F | Instantaneous Forward Voltage | — | 0.60 | 0.65 | V | I _F = 3A ⁽²⁾ |
| | | — | 0.78 | 0.84 | V | I _F = 10A ⁽²⁾ |
| I _R | Reverse Leakage Current | — | 8 | 15 | μA | V _R = 150V |
| T _J , T _{STG} | Operating and Storage Temperature | -40°C to 150°C Max | | | | |